

Student Program: ICOM-CC 2026 Sponsorship

Overview

Bev/Art is committed to the future of heritage conservation, and that includes supporting the people who will carry the field forward. This year, we're launching a program for graduate-level students in archives, libraries, museums and related conservation disciplines as they take their first steps into professional practice.

The program begins with a partnership we're especially proud of: the International Council of Museums Committee for Conservation Triennial Conference, being held 14-18 September in Oslo, where Bev/Art is headquartered. We will sponsor two students to attend through a collaboration with the host committee at Nasjonalmuseet — selected students will receive conference admission and accommodations.

Eligibility Requirements

To apply, you must:

- Be a current graduate student or recent graduate (within one year) studying conservation — including but not limited to objects, paintings, textiles, paper, photography, archaeology or architectural conservation
- Be available to travel to Oslo for the conference dates (Sept. 14-18 2026)
- Be able to cover the cost of travel to and from Oslo
- Be willing to participate in interviews for Bev/Art and ICOM-CC social media and blogs
- Submit your essay in English (essays must be written by you, not AI)

How to Apply

Apply at <https://www.bev.art/icomcc-2026/student-sponsorship>

Submit a written essay (500-750 words) addressing the following:

- Why do you want to attend this conference?
- What do you hope to learn or gain from attending?
- How would this experience impact your studies or early career in conservation?

Selection Criteria

We're looking for essays that demonstrate genuine interest in conservation and personal motivation for attending this specific opportunity. Strong applications will show thoughtfulness and self-awareness about how the conference fits into your development as a conservator.

We welcome all levels of English proficiency and understand that many applicants will have English as a second language.

We particularly encourage applications from students who face financial or structural barriers to attending independently and those who would benefit from expanded professional exposure and networking opportunities.

Application Window

Submissions will be accepted beginning 23 February through 11:59 CET on 29 March.